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APPLICATION NO.		FILING DATE		FIRST NAMED INVENTOR		ATTOR	RNEY DOCKET NO.	CONFIRMATION NO.		
10/612,222		07	/03/2003	Masatoshi Akagawa			300.1119	5751		
21171	21171 7590 12/08/2006						EXAMINER			
STAAS & HALSEY LLP							CHANG, RICK KILTAE			
SUITE 700 1201 NEW YORK AVENUE, N.W.							ART UNIT	PAPER NUMBER	_	
WASHINGTON, DC 20005						•	3726			

DATE MAILED: 12/08/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)							
Office Action Summary	10/612,222	AKAGAWA ET AL.							
Office Action Summary	Examiner	Art Unit							
	Rick K. Chang	3726							
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence address							
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication.  If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be timus will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONF.	N. nely filed the mailing date of this communication. D. (35 U.S.C. & 133)							
Status									
1) Responsive to communication(s) filed on 14 No.	ovember 2006.	•							
3) Since this application is in condition for allowar	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is								
closed in accordance with the practice under E	The state of the s								
Disposition of Claims		·							
4)⊠ Claim(s) <u>1-36 and 49</u> is/are pending in the app	lication.								
4a) Of the above claim(s) that are not listed in it		m consideration.							
5) Claim(s) is/are allowed.									
6) Claim(s) <u>1,2,4-8,11-20,22-26 and 29-36</u> is/are	rejected.	·							
7) Claim(s) is/are objected to.									
8) Claim(s) are subject to restriction and/or	election requirement.								
Application Papers									
9) The specification is objected to by the Examine	r.								
10) The drawing(s) filed on is/are: a) acce	epted or b) objected to by the E	Examiner.							
Applicant may not request that any objection to the									
Replacement drawing sheet(s) including the correcti	on is required if the drawing(s) is obj	ected to. See 37 CFR 1.121(d).							
11)☐ The oath or declaration is objected to by the Ex	aminer. Note the attached Office	Action or form PTO-152.							
Priority under 35 U.S.C. § 119	•								
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of:	priority under 35 U.S.C. § 119(a)	-(d) or (f).							
1.☐ Certified copies of the priority documents	s have been received								
2.☐ Certified copies of the priority documents		on No							
3. Copies of the certified copies of the prior									
application from the International Bureau		- m and readerial ciago							
* See the attached detailed Office action for a list.o	• • • • • • • • • • • • • • • • • • • •	d.							
httschmont/e)									
Attachment(s) ) Notice of References Cited (PTO-892)	4) 🗖 Inton : 0	(DTO 442)							
Notice of Praftsperson's Patent Drawing Review (PTO-948)	4) Interview Summary ( Paper No(s)/Mail Da								
Information Disclosure Statement(s) (PTO/SB/08)	5) 🔲 Notice of Informal Pa								
Paper No(s)/Mail Date	6)	•							

#### **DETAILED ACTION**

### Continued Examination Under 37 CFR 1.114

1. All claims are drawn to the same invention claimed in the application prior to the entry of the submission under 37 CFR 1.114 and could have been finally rejected on the grounds and art of record in the next Office action if they had been entered in the application prior to entry under 37 CFR 1.114. Accordingly, **THIS ACTION IS MADE FINAL** even though it is a first action after the filing of a request for continued examination and the submission under 37 CFR 1.114. See MPEP § 706.07(b). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

#### Election/Restrictions

2. Newly submitted claim 49 directed to an invention that is independent or distinct from the invention originally claimed for the following reasons: the process as claimed can be practiced by another and materially different apparatus such as a camcorder.

Since applicant has received an action on the merits for the originally presented invention, this invention has been constructively elected by original presentation for prosecution on the merits. Accordingly, claim 49 is withdrawn from consideration as being directed to a non-elected invention. See 37 CFR 1.142(b) and MPEP § 821.03.

### Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 4. Claims 1-2, 4-8, 11-13, 15, and 17 are rejected under 35 U.S.C. 102(b) as being anticipated by Leedy (US 5,103,557).

Leedy discloses a first detection step (col. 5, lines 1-68 and col. 6, lines 1-44); Figs. 4a-4b show first holding step and a first correction step; col. 6, lines 45-68 and entire col. 7 disclose E-beam means (maskless), forming vias and additional insulating layers. Col. 6, lines 45-47 states that the modified net list is used to form interconnect patterns. The process involces depositing a layer of insulation over the wafer surface and forming metal deposited vias to connect with the underlying electrical components formed under the insulation layer (col. 6, lines 48-64). Col. 6, lines 65-68 and col. 7 state that the metallization is repeated.

## Claim Rejections - 35 USC § 103

- 5. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person

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having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

6. Claims 19-20, 22-26, and 29-36 are rejected under 35 U.S.C. 103(a) as being unpatentable over Leedy (US 5,103,557) in view of Kulkarni et al (US 5,991,699).

Leedy teaches the invention as described with respect to claims 1-2, 4-8, 11-13, 15, and 17 above, except for imaging means and a second correction step of correcting the design data so as to move the wiring line away from the terminal of the other electronic component.

Kulkarni discloses in a number of figures, for example Figs. 3 and 10b), indentifying defects and issuing corrective actions and imaging means (col. 6, lines 8-34).

It would have been obvious to one of ordinary skill in the art at the time the invention was made to modify Leedy by identifying defects such as a terminal is displaced and intersects with a wiring line and correcting the design data so as to move the wiring line away from the terminal of the other electronic component and providing imaging means, as taught by Kulkarni, for the purpose of reducing total number of defects to the electronic components and providing defects in a digitized format.

7. Claims 14, 16, and 18 are rejected under 35 U.S.C. 103(a) as being unpatentable over Leedy (US 5,103,557) in view of Kulkarni et al (US 5,991,699).

Leedy fails to disclose a second correction step of correcting the design data so as to move the wiring line away from the terminal of the other electronic component.

Kulkarni discloses in numerous figures, for example Figs. 3 and 10b), indentifying defects and issuing corrective actions.

It would have been obvious to one of ordinary skill in the art at the time the invention was made to modify Leedy by identifying defects such as a terminal is displaced and intersects with a

wiring line and correcting the design data so as to move the wiring line away from the terminal of the other electronic component, as taught by Kulkarni, for the purpose of reducing total number of defects to the electronic components.

### Response to Arguments

8. Applicant's arguments filed 11/14/06 have been fully considered but they are not persuasive.

As stated above, Col. 6, lines 45-47 states that the modified net list is used to form interconnect patterns. The process involces depositing a layer of insulation over the wafer surface and forming metal deposited vias to connect with the underlying electrical components formed under the insulation layer (col. 6, lines 48-64). Col. 6, lines 65-68 and col. 7 state that the metallization is repeated.

### Interviews After Final

9. Applicant note that an interview after a final rejection must be submitted briefly in writing the intended purpose and content of the interview (the agenda of the interview must be in writing). Upon review of the agenda, the Examiner may grant the interview if the examiner is convinced that disposal or clarification for appeal may be accomplished with only nominal further consideration. Interviews merely to restate arguments of record or to discuss new limitations will be denied. See MPEP 714.13 and 713.09.

#### Conclusion

10. Please provide reference numerals (either in parentheses next to the claimed limitation or in a table format with one column listing the claimed limitation and another column listing corresponding reference numerals in the remark section of the response to

the Office Action) to all the claimed limitations as well as support in the disclosure for better clarity (optional). Applicants are duly reminded that a full and proper response to this Office Action that includes any amendment to the claims and specification of the application as originally filed requires that the applicant point out the support for any amendment made to the disclosure, including the claims. See 37 CFR 1.111 and MPEP 2163.06.

11. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Rick K. Chang whose telephone number is (571) 272-4564. The examiner can normally be reached on 5:30 AM to 1:30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David P. Bryant can be reached on (571) 272-4526. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <a href="http://pair-direct.uspto.gov">http://pair-direct.uspto.gov</a>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

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RICHARD CHANG PRIMARY EXAMINER

RC

December 5, 2006